

IN THE CLAIMS:

Please cancel Claim 6 without prejudice or disclaimer of subject matter and amend Claim 1 as follows:

1. (Currently Amended) A laser exposing apparatus comprising
a first laser source emitting a first laser beam;
a second laser source emitting a second laser beam shorter in wavelength than the first laser beam;
optical means for directing the first laser beam and the second laser beam to a photosensitive member; and
adjusting means for selectable adjustment of respective optical path lengths of the first and second laser beams so that the optical path length of the first laser beam is set to be relatively shorter than the optical path length of the second laser beam which is set to be relatively longer.

wherein optical paths having shorter and longer optical path lengths from the respective laser source to the photosensitive member are arranged consecutively, and said adjusting means sets the longer optical path length to the optical path of the second laser beam.

2. (Original) A laser exposing apparatus according to Claim 1, wherein the first laser source and the second laser source are provided in a semiconductor chip.

3. (Previously Presented) A laser exposing apparatus according to Claim 1, wherein said optical means comprises lenses having refractive indices that differ depending on wavelength.

4. (Cancelled)

5. (Previously Presented) A laser exposing apparatus according to Claim 2, wherein said adjusting means has a rotating mechanism for rotating the semiconductor chip with substantially a center between the first laser source and the second laser source as the center of rotation.

6. (Previously Presented) A laser exposing apparatus according to Claim 1, wherein optical paths having shorter and longer optical path lengths from the respective laser sources to the photosensitive member are arranged consecutively, and said adjusting means sets the optical path length to the optical path of the second laser beam.